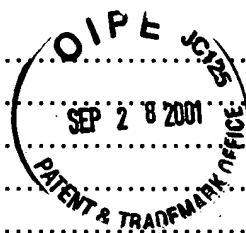


EL844051793

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No. 09/233/377-4 2001
Filing Date January 18, 1999
Inventor Gurtej S. Sandhu et al.
Assignee Micron Technology, Inc.
Group Art Unit 2813
Examiner T. Pham
Attorney's Docket No. MI22-1114
Title: Method of Forming a Refractory Metal Silicide (as Amended)



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RESPONSE TO JUNE 28, 2001 OFFICE ACTION

To: Box Non-Fee Amendment
Assistant Commissioner for Patents
Washington, D.C. 20231

From: Bernard Berman (Tel. 509-624-4276; Fax 509-838-3424)
Wells, St. John, Roberts, Gregory & Matkin P.S.
601 W. First Avenue, Suite 1300
Spokane, WA 99201-3828

Sir:

Responsive to the Office Action dated June 28, 2001, Applicant respectfully requests reconsideration of the above-referenced application in view of the amendments and remarks that follow.